



Subst. Form PTO-1449

Atty. Docket No.: P00100US1A/
FIR 2 0083

Serial No.: 10/074,907

APPLICANT'S(S) INFORMATION
DISCLOSURE STATEMENT

Applicant(s): Hogan et al.

Filing Date: February 12, 2002

Group: Unknown

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U.S. PATENT DOCUMENTS

Initial*		Document No.	Date	Name	Class	Subcl.	Filing Date
RM	BA	5,580,925	03DE1996	Iwahara et al.			
	BB	5,627,252	06MY1997	De La Croi Habimana			
	BC	5,728,791	17MR1998	Tamai et al.			
	BD	5,733,975	31MR1998	Aoyama et al.			
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	BG	5,811,501	22SE1998	Chiba et al.			
	BH	5,834,563	10NO1998	Kimura et al.			
	BI	5,849,847	15DE1998	Quirk			
	BJ	5,855,972	05JA1999	Kaeding			
	BK	6,011,116	04JA2000	Aoyama et al.			
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	BM	6,025,416	15FE2000	Proebster et al.			
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Examiner:	MT Hurl	Date Considered: 6-8-03

* EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if in conformance and not considered. Include copy of this form with next communication to applicant.



Subst. Form PTO-1449

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Serial No.: 10/074,902

APPLICANT'S(S) INFORMATION
DISCLOSURE STATEMENT

Applicant(s): Hogan et al.

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Initial*		Document No.	Date	Name	Class	Subcl.	Filing Date
RH	AA	4,463,129	31JL1984	Shinada et al.			
	AB	4,543,403	24SE1985	Isayama et al.			
	AC	4,788,254	29NO1988	Kawakubo et al.			
	AD	4,829,130	09MY1989	Licchelli et al.			
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RH	AT	Greenwood, N.N.; Earnshaw, A., Chemistry of the Elements, pp 1126-1127, Pergamon Press, New York 1984
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Examiner: Brent Hall

Date Considered: 12-8-03

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Initial*		Document No.	Date	Name	Class	Subcl.	Filing Date
NY	AA	6,277,304	21AU2001	Wei et al.			
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	AV	EP 1 134 251 A1	19.09.2001	EPO			
NY	AW	EP 1 099 728 A1	16.05.2001	EPO			

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